

DOCKET NO: 288992US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :  
YASUO MATSUKI, ET AL. : ATTN: APPLICATION DIVISION  
SERIAL NO: NEW U.S. PCT APPLICATION :  
(BASED ON PCT/JP04/15101)  
FILED: HEREWITH :  
FOR: COMPOSITION FOR FORMING :  
SILICON-COBALT FILM, SILICON-  
COBALT FILM AND METHOD FOR  
FORMING SAME

PRELIMINARY AMENDMENT

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

Prior to examination on the merits, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 4 of this paper.